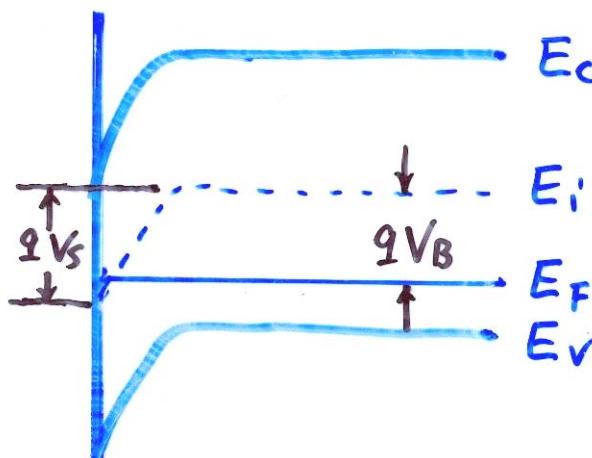


# 10.2 表面电场效应<sub>2</sub>

## 10.2.1 空间电荷层

表面势  $V_s$  — 空间电荷层两端的电势差，表面比内部高为正

$$E_c(x) = E_{c0} - qV(x)$$

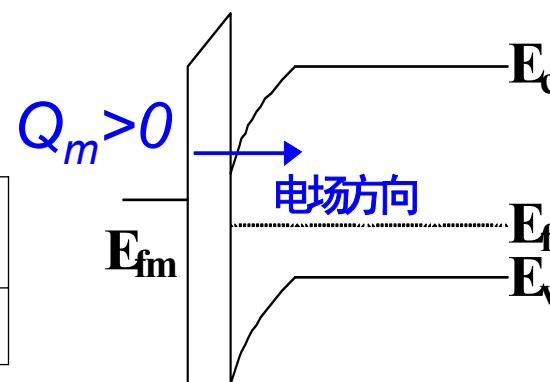


$$V_s = -\frac{E_{is} - E_{ib}}{q}$$

| $Q_m$ | $V_s$ | $Q_s$ | 能带弯曲 |
|-------|-------|-------|------|
| +     | +     | -     | ↓    |
| -     | -     | +     | ↑    |

助记例子：

| $Q_m$ | $V_s$ | $Q_s$ | 能带弯曲 |
|-------|-------|-------|------|
| +     | +     | -     | ↓    |

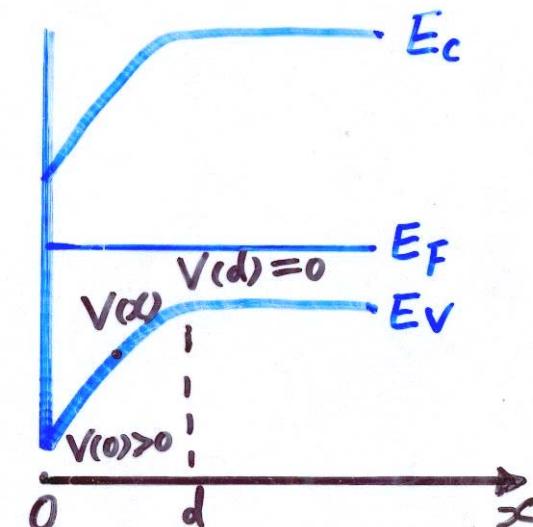


电力线从正电荷出发终止于负电荷，电势沿电力线方向减小

# 10.2 表面电场效应<sub>3</sub>

## 10.2.2 空间电荷层中的泊松方程

- 假设
- 1° 半导体表面是个无限大的面，其线度>>空间电荷层厚度→一维近似， $(\rho, E, V)$  不依赖  $y, z$
  - 2° 半导体厚度  $>>$  空间电荷层厚度→半导体体内电中性
  - 3° 半导体均匀掺杂
  - 4° 非简并统计适用于空间电荷层
  - 5° 不考虑量子效应



# 10.2 表面电场效应<sub>3</sub>

## 10.2.2 空间电荷层中的泊松方程

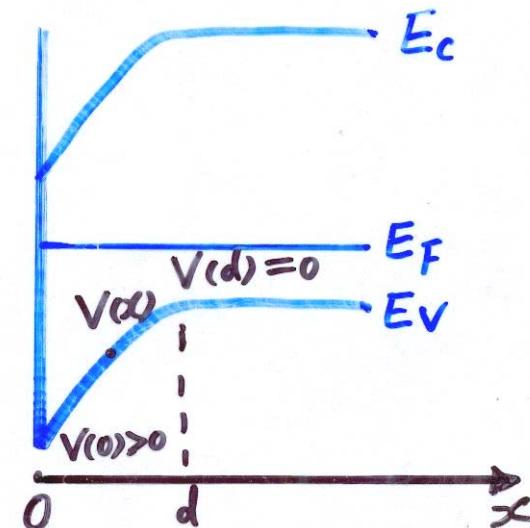
例子：一维p型半导体

$$\frac{d^2V(x)}{dx^2} = -\frac{\rho(x)}{\epsilon_s} \quad \text{泊松方程}$$

$$\rho(x) = q(N_D^+ - N_A^- + p_p - n_p)$$

$$\left. \begin{array}{l} n_p = n_{p0} \exp(qV/kT) \\ p_p = p_{p0} \exp(-qV/kT) \end{array} \right\} \text{玻尔兹曼统计}$$

已知  $x \rightarrow +\infty$  时  $\rho(x) = 0 \rightarrow N_D^+ - N_A^- = n_{p0} - p_{p0}$



$$\frac{d^2V(x)}{dx^2} = \frac{dV}{dx} \cdot \frac{d}{dV} \left( \frac{dV}{dx} \right) = -\frac{q}{\epsilon_s} \left\{ p_{p0} [\exp(-qV/kT) - 1] - n_{p0} [\exp(qV/kT) - 1] \right\}$$

# 10.2 表面电场效应<sub>4</sub>

## 10.2.2 空间电荷层中的泊松方程

例子：一维p型半导体

$$\frac{d^2V(x)}{dx^2} = -\frac{\rho(x)}{\epsilon_s}$$

$\downarrow$  两边乘以  $dV$

$$\frac{dV}{dx} d\left(\frac{dV}{dx}\right) = -\frac{q}{\epsilon_s} \left\{ p_{p0} [\exp(-qV/kT) - 1] - n_{p0} [\exp(qV/kT) - 1] \right\} dV$$

$\downarrow$  从空间电荷层内边界积分到表面

$$\int_0^{dv} \frac{dV}{dx} d\left(\frac{dV}{dx}\right) = \int_0^V \left( -\frac{q}{\epsilon_s} \right) \left\{ p_{p0} [\exp(-qV/kT) - 1] - n_{p0} [\exp(qV/kT) - 1] \right\} dV$$

$\downarrow$   $E = -\frac{dV(x)}{dx}$

$$E^2(x) = \left( \frac{2kT}{q} \right)^2 \left( \frac{q^2 p_{p0}}{2\epsilon_s kT} \right) \left\{ \left[ \exp\left(-\frac{qV}{kT}\right) + \frac{qV}{kT} - 1 \right] + \frac{n_{p0}}{p_{p0}} \left[ \exp\left(\frac{qV}{kT}\right) - \frac{qV}{kT} - 1 \right] \right\}$$

# 10.2 表面电场效应<sub>5</sub>

## 10.2.2 空间电荷层中的泊松方程

例子：一维p型半导体

$$E^2(x) = \left(\frac{2kT}{q}\right)^2 \left(\frac{q^2 p_{p0}}{2\epsilon_s kT}\right) \left\{ \left[ \exp\left(-\frac{qV}{kT}\right) + \frac{qV}{kT} - 1 \right] + \frac{n_{p0}}{p_{p0}} \left[ \exp\left(\frac{qV}{kT}\right) - \frac{qV}{kT} - 1 \right] \right\}$$

$$E(x) = \pm \frac{2kT}{qL_D} F\left(\frac{qV(x)}{kT}, \frac{n_{p0}}{p_{p0}}\right)$$

“+” :  $V > 0$   
“-” :  $V < 0$

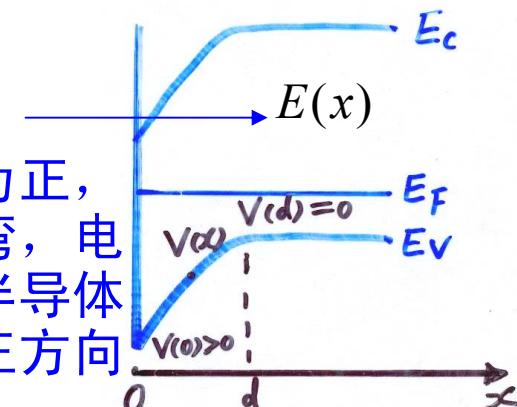
德拜长度  
(p型半导体)

$$L_D = \left( \frac{2\epsilon_s kT}{q^2 p_{p0}} \right)^{1/2}$$

$$F\left(\frac{qV}{kT}, \frac{n_{p0}}{p_{p0}}\right) = \left\{ \left[ \exp\left(-\frac{qV}{kT}\right) + \frac{qV}{kT} - 1 \right] + \frac{n_{p0}}{p_{p0}} \left[ \exp\left(\frac{qV}{kT}\right) - \frac{qV}{kT} - 1 \right] \right\}^{1/2}$$

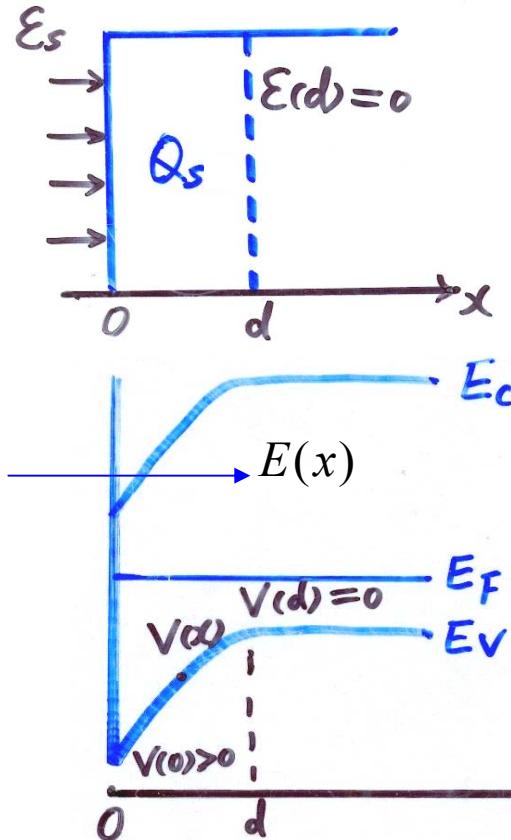
F 函数，无量纲数

表面势为正，  
能带下弯，电  
场指向半导体  
内部为正方向



# 10.2 表面电场效应<sub>6</sub>

## 10.2.3 半导体表面电场、电势和电容



$$E(x) = \pm \frac{2kT}{qL_D} F\left(\frac{qV(x)}{kT}, \frac{n_{p0}}{p_{p0}}\right)$$

$\downarrow$

$x = 0 \quad V(0) = V_s$

$E_s = \pm \frac{2kT}{qL_D} F\left(\frac{qV_s}{kT}, \frac{n_{p0}}{p_{p0}}\right)$

$\downarrow$

$$Q_s = -\varepsilon_s E_s = \mp \frac{2\varepsilon_s kT}{qL_D} F\left(\frac{qV_s}{kT}, \frac{n_{p0}}{p_{p0}}\right)$$

$$C_s = \left| \frac{dQ_s}{dV_s} \right| = \frac{\varepsilon_s}{L_D} \left\{ \left[ -\exp\left(-\frac{qV_s}{kT}\right) + 1 \right] + \frac{n_{p0}}{p_{p0}} \left[ \exp\left(\frac{qV_s}{kT}\right) - 1 \right] \right\} \Bigg/ F\left(\frac{qV_s}{kT}, \frac{n_{p0}}{p_{p0}}\right)$$

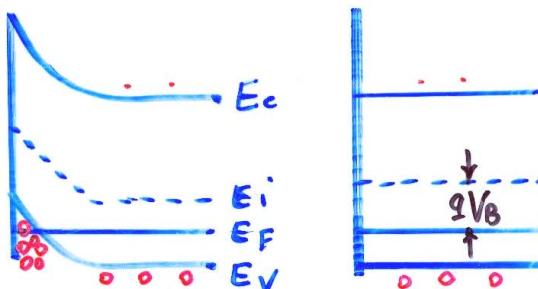
# 10.2 表面电场效应<sub>7</sub>

## 10.2.4 半导体表面层的五种基本状态

1° 多子堆积（积累）状态  $Q_s \propto \exp(-qV_s/2kT) \quad V_s < 0$

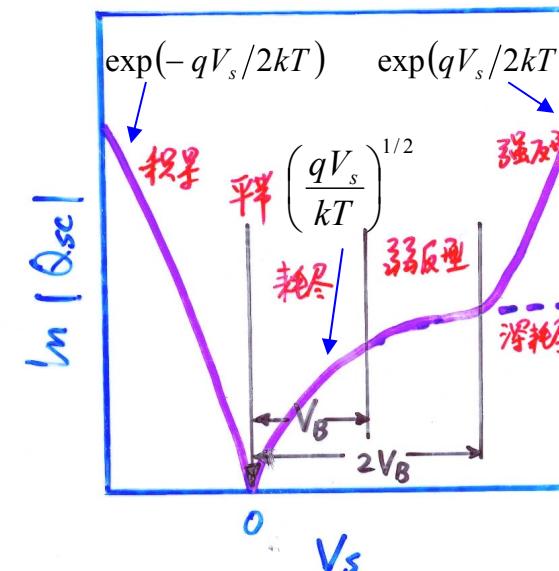
2° 平带状态  $C_{FBS} = \lim_{V_s \rightarrow 0} \frac{dQ_s}{dV_s} = \frac{\sqrt{2}\epsilon_s}{L_D} \left( 1 + \frac{n_{p0}}{p_{p0}} \right)^{1/2} \approx \frac{\sqrt{2}\epsilon_s}{L_D} \quad V_s = 0$

$$Q_s \propto E_s \propto F(V_s) = \left\{ \left[ \exp\left(-\frac{qV_s}{kT}\right) + \frac{qV_s}{kT} - 1 \right] + \frac{n_{p0}}{p_{p0}} \left[ \exp\left(\frac{qV_s}{kT}\right) - \frac{qV_s}{kT} - 1 \right] \right\}^{1/2}$$



积累

$V_s < 0$



平带

$V_s = 0$

# 10.2 表面电场效应。

## 10.2.4 半导体表面层的五种基本状态

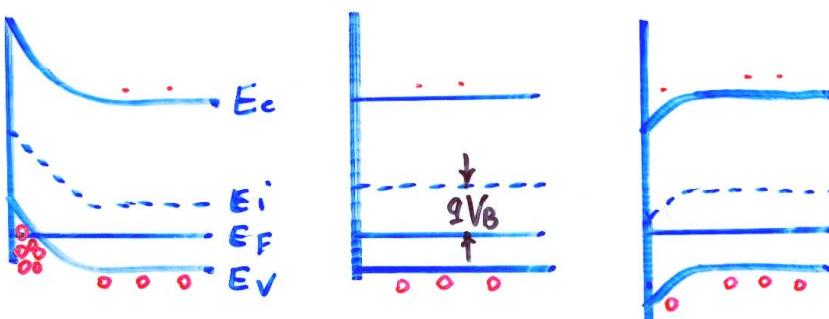
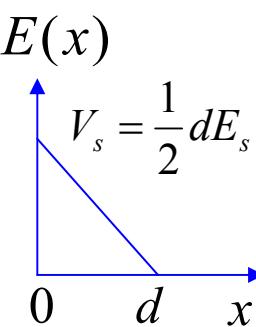
3° 耗尽状态  $F\left(\frac{qV_s}{kT}, \frac{n_{p0}}{p_{p0}}\right) = \left(\frac{qV_s}{kT}\right)^{1/2}$   $Q_s = -\frac{2\epsilon_s kT}{qL_D} \left(\frac{qV_s}{kT}\right)^{1/2} L_D = \left(\frac{2\epsilon_s kT}{q^2 p_{p0}}\right)^{1/2}$

$V_B > V_s > 0$

另一种求解面电荷密度的途径—“耗尽层近似”

$$Q_s = -qN_A \left( \frac{2\epsilon_s}{q} \frac{V_s}{N_A} \right)^{1/2} = -(2\epsilon_s q N_A V_s)^{1/2}$$

$$d = \left( \frac{2\epsilon_s}{q} \frac{V_s}{N_A} \right)^{1/2}$$



积累

$$V_s < 0$$

平带

$$V_s = 0$$

耗尽

$$V_s \in (0, V_B)$$

